

IN THE CLAIMS

Claims 1-10 (Canceled).

11 (Currently Amended). A method comprising:

depositing forming a conductive layer over photoresist to enable radiation to pass through said layer; and

exposing said photoresist to an electric field using said layer.

Claim 12 (Canceled).

13 (Original). The method of claim 11 including depositing a conductive material to form said layer and removing said layer after the photoresist is developed.

14 (Original). The method of claim 11 including spinning on said conductive layer.

15 (Original). The method of claim 11 wherein forming a conductive layer includes depositing a water soluble conductive material to act as said conductive electrode.

Claims 16-19 (Canceled).

20 (Currently Amended). A method comprising:

exposing photoresist to radiation; and

while exposing said photoresist to radiation, exposing said photoresist to an electric field using an electrode with an opening to permit the passage of radiation.

Claims 21 and 22 (Canceled).

23 (Original). The method of claim 20 including exposing said photoresist to an electric field using a radio frequency coil to induce said electric field.

24 (Original). The method of claim 20 including exposing the photoresist to extreme ultraviolet radiation.

Claims 25-40 (Canceled).

41 (New). A method comprising:
forming a conductive layer over photoresist;
exposing said photoresist to an electric field using said layer; and
depositing a conductive material to form said layer and removing said layer after the photoresist is developed.

42 (New). A method comprising:
forming a conductive layer over photoresist by depositing a water soluble conductive material to act as said conductive electrode; and
exposing said photoresist to an electric field using said layer.

43 (New). A method comprising:
exposing photoresist to radiation;
while exposing said photoresist to radiation, exposing said photoresist to an electric field; and
exposing said photoresist to radiation through an electrode which is thin enough to allow said radiation to pass.